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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/849,311	05/19/2004	Liubo Hong	HT03-038	5787	
75	90 09/07/2005		EXAM	EXAMINER	
STEPHEN B. ACKERMAN 28 DAVIS AVENUE POUGHKEEPSIE, NY 12603			KENNEDY, JENNIFER M		
			ART UNIT	PAPER NUMBER	
			2812		
			DATE MAILED: 09/07/2003	5	

Please find below and/or attached an Office communication concerning this application or proceeding.

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## **Advisory Action**

	Application No.	Applicant(s)	
10/849,311		HONG ET AL.	
	Examiner	Art Unit	
	1	0040	
	Jennifer M. Kennedy	2812	

Before the Filing of an Appeal Brief	Examiner	Art Unit			
•	Jennifer M. Kennedy	2812			
The MAILING DATE of this communication appe	ars on the cover sheet with the o	correspondence add	lress		
THE REPLY FILED <u>17 August 2005</u> FAILS TO PLACE THIS A	PPLICATION IN CONDITION FOR	R ALLOWANCE.			
<ol> <li>The reply was filed after a final rejection, but prior to or o this application, applicant must timely file one of the follop places the application in condition for allowance; (2) a No (3) a Request for Continued Examination (RCE) in comp following time periods:</li> <li>The period for reply expires 3 months from the mailing date of</li> </ol>	n the same day as filing a Notice of owing replies: (1) an amendment, a otice of Appeal (with appeal fee) in Iliance with 37 CFR 1.114. The rep	of Appeal. To avoid al offidavit, or other evid compliance with 37 (	ence, which CFR 41.31; or		
b) The period for reply expires on: (1) the mailing date of this Adv		e final rejection, whichev	er is later. In no		
event, however, will the statutory period for reply expire later th  Examiner Note: If box 1 is checked, check either box (a) or (b)  MONTHS OF THE FINAL REJECTION. See MPEP 706.07(f  Extensions of time may be obtained under 37 CFR 1.136(a). The date on	an SIX MONTHS from the mailing date o . ONLY CHECK BOX (b) WHEN THE F ).	f the final rejection. IRST REPLY WAS FILE	D WITHIN TWO		
been filed is the date for purposes of determining the period of extension a CFR 1.136(a). The date on been filed is the date for purposes of determining the period of extension a CFR 1.17(a) is calculated from: (1) the expiration date of the shortened stabove, if checked. Any reply received by the Office later than three month earned patent term adjustment. See 37 CFR 1.704(b).  NOTICE OF APPEAL	and the corresponding amount of the fee. atutory period for reply originally set in the	The appropriate extension of (2)	on fee under 37 as set forth in (b)		
<ol> <li>The Notice of Appeal was filed on A brief in com of filing the Notice of Appeal (37 CFR 41.37(a)), or any e Since a Notice of Appeal has been filed, any reply must</li> </ol>	extension thereof (37 CFR 41.37(e)	), to avoid dismissal	of the appeal.		
<u>AMENDMENTS</u> 3. The proposed amendment(s) filed after a final rejection,	but prior to the date of filing a brid	of will not be entered	hecause		
(a) ☐ They raise new issues that would require further co (b) ☐ They raise the issue of new matter (see NOTE below	onsideration and/or search (see NC ow);	OTE below);			
(c) They are not deemed to place the application in be appeal; and/or	•		g the issues for		
(d) ☐ They present additional claims without canceling a NOTE: (See 37 CFR 1.116 and 41.33(a))					
4. The amendments are not in compliance with 37 CFR 1.		ompliant Amendmen	t (PTOL-324).		
5. Applicant's reply has overcome the following rejection(s		e Lei L. d.			
6. Newly proposed or amended claim(s) would be a the non-allowable claim(s).					
7.  For purposes of appeal, the proposed amendment(s): a) how the new or amended claims would be rejected is proposed the status of the claim(s) is (or will be) as follows: Claim(s) allowed:	l∐ will not be entered, or b) ∐ vovided below or appended.	vill be entered and an	explanation of		
Claim(s) allowed: Claim(s) objected to: Claim(s) rejected:					
Claim(s) withdrawn from consideration:					
AFFIDAVIT OR OTHER EVIDENCE	but before or on the date of filing a	Notice of Appeal will	not be entered		
<ol> <li>The affidavit or other evidence filed after a final action, because applicant failed to provide a showing of good at and was not earlier presented. See 37 CFR 1.116(e).</li> </ol>	nd sufficient reasons why the affida	avit or other evidence	is necessary		
☐ The affidavit or other evidence filed after the date of filing a Notice of Appeal, but prior to the date of filing a brief, will <u>not</u> be entered because the affidavit or other evidence failed to overcome <u>all</u> rejections under appeal and/or appellant fails to provide a showing a good and sufficient reasons why it is necessary and was not earlier presented. See 37 CFR 41.33(d)(1).					
10. ☐ The affidavit or other evidence is entered. An explanation REQUEST FOR RECONSIDERATION/OTHER	on of the status of the claims after	entry is below or atta	ched.		
11.  The request for reconsideration has been considered b  See Continuation Sheet.	ut does NOT place the application	in condition for allow	ance because:		
12.  Note the attached Information Disclosure Statement(s)	. (PTO/SB/08 or PTO-1449) Paper		.1		
13.  Other:		Junifer M. Kenne Primary Examiner	Gennedy		
		Art Unit: 2812			

Continuation of 11. does NOT place the application in condition for allowance because: Applicant's arguments filed 8/17/2005 have been fully considered but they are not persuasive. Applicant argues that the AAPA does not disclose the method of planarizing since the thickness loss typically varies across the wafer. The examiner disagrees and notes that the AAPA teaches on page 3 a "CMP process is preformed for planarizing the insulation layer 5 so that the top surface of the cap layer 15 is exposed as an electrical contact point for a subsequent second conductive layer." Clearly, this is a planarization step. The Applicants also argue that the AAPA does not teach a method that minimizes the cap layer thickness loss. The examiner notes that the combination of the AAPA and Huang et al. teach the method of planarizing with a CMP step prior to exposing a cap layer and then performing a RIE step. In response to applicant's arguments against the references individually, one cannot show nonobviousness by attacking references individually where the rejections are based on combinations of references. See In re Keller, 642 F.2d 413, 208 USPQ 871 (CCPA 1981); In re Merck & Co., 800 F.2d 1091, 231 USPQ 375 (Fed. Cir. 1986).

Further, Applicants argue that Huang does not having the cap layer thickness variation of less than +/- 5 Angstroms. The examiner notes that the referenced column and line numbers refer to the overall wafer uniformity, which would include that of the cap layer. Applicants argue that Huang et al. only teach a etch uniformity of +/- 5% when referring to the IMD layer. The examiner notes that Huang et al. has a general teaching that RIE allows for a +/- 5% uniformity across the wafer, and when the RIE etching is applied to the combined AAPA, Huang and Park the uniformity across the wafer would reflect in the cap layer that is exposed in Park et al.

Finally, Applicants argue that Park does not disclose the method of planarizing the insulating layer at a certain distance below said capping layer. The examiner disagrees and notes that, as seen by Figure 9, Park discloses a planar insulating layer after the etch back process. MPEP 2125 states that drawings and pictures can anticipate claims if they clearly show the structure which is claimed. In re Mraz, 455 F.2d 1069, 173 USPQ 25 (CCPA 1972). However, the picture must show all the claimed structural features and how they are put together. Jockmus v. Leviton, 28 F.2d 812 (2d Cir. 1928). The origin of the drawing is immaterial. For instance, drawings in a design patent can anticipate or make obvious the claimed invention as can drawings in utility patents. When the reference is a utility patent, it does not matter that the feature shown is unintended or unexplained in the specification. The drawings must be evaluated for what they reasonably disclose and suggest to one of ordinary skill in the art. In re Aslanian, 590 F.2d 911, 200 USPQ 500 (CCPA 1979). See MPEP § 2121.04 for more information on prior art drawings as "enabled disclosures." In a 35U.S.C. 102(e)/103(a) rejection over a prior art patent, the reference patent is available for all that it fairly discloses to one of ordinary skill in the art, regardless of what is claimed. In re Bowers, 359 F.2d 886, 149 USPQ 570 (CCPA 1966).

Further, assuming that Park did not disclose planarizing, which the examiner does not agree with, but did disclose the method of recessing the insulating layer at a certain distance below the capping layer, the combined references of AAPA and Huang et al. disclose the method of first planarizing the insulating film over the capacitor and Park discloses that it would be beneficial to continue the planarization below the level of the capping layer to ensure that all insulation material is removed form the surface of the layer to allow for subsequent electrical connection. Therefore, the combination still reads on each and every limitation of the claims. In response to applicant's arguments against the references individually, one cannot show nonobviousness by attacking references individually where the rejections are based on combinations of references. See In re Keller, 642 F.2d 413, 208 USPQ 871 (CCPA 1981); In re Merck & Co., 800 F.2d 1091, 231 USPQ 375 (Fed. Cir. 1986).